Hydridosilicate σ -Complexes

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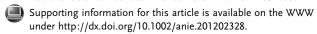
Stabilization of ArSiH₄⁻ and SiH₆²⁻ Anions in Diruthenium Si-H **σ-Complexes****

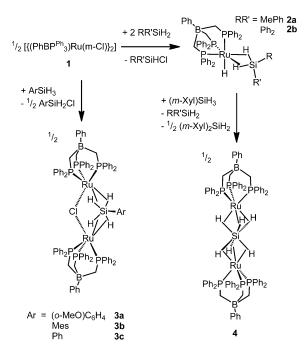
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Transition-metal centers are known to stabilize a wide variety of highly reactive species, [1,2] and this is often attributed to the presence of strong d_{π} -back-donation from the metal to formally empty π -symmetry orbitals on the ligated species.^[3] Many unsaturated silicon species can be stabilized in this way, and examples include silvlene, [2b,c] silene, [2d,e] disilene, [2f,g] and silabenzene $^{[2h,i]}$ complexes. The transition-metal stabilization of saturated, reactive species as σ-complexes is less common, but examples involving hypercoordinate silicon centers have recently been reported, such as the hydridosilicate σ-complexes $L_nM[\eta^3-H_2SiR_3]$ (R = H, alkyl, aryl, Cl; L_nM = CpFe-(PiPr₂Me), [4a] TpRu(PPh₃)[4b]). Related metal complexes of the type $L_3MH_3SiR_3$ (M = Fe, Ru, Os, L = R_3P , H_2 , CO) may possess significant $[L_3M\{\eta^4-H_3SiR_3\}]$ character, [5] but these have more typically been described as silyl complexes^[6a-d] or η^2 -HSiR₃^[6e] σ -complexes with additional secondary Si···H interactions. [6] It is interesting that transition metals can participate in the formation and stabilization of hydridosilicate anions since these anions are usually highly reactive and have most often been studied as transient intermediates^[7] or in the gas phase. [8] The few examples of [HSiR₄] and $[H_2SiR_3]^-$ salts (R = Ar, OR, F) that have been isolated are highly reactive, [9] and transition-metal complexes of these anions may also exhibit interesting reactivity. [4b] Given the unusual structures of hydridosilicate σ -complexes and their potential role in metal-mediated transformations, it is important to more fully develop the chemistry of these hypercoordinate silicon species.

We recently reported unusual silane σ-complexes $[\{PhBP^{Ph}_{3}\}RuH(\eta^{3}-H_{2}SiRR')]$ $(RR'=Me,Ph\ 2a;\ RR'=Ph_{2}$ 2b) that feature formal donation of two Si-H bonds to ruthenium. These compounds were obtained by reaction of secondary silanes with $[\{(PhBP_{3}^{Ph})Ru(\mu-Cl)\}_{2}]$ (1), as illustrated by the synthesis of complexes 2 a,b (Scheme 1). These complexes are highly electrophilic at silicon, and readily add Lewis bases to form $[{PhBP_{3}^{Ph}}Ru\{(\mu-H)_{3}SiRR'(base)\}]$ complexes with hypercoordinate silicon centers. [10] Similar chemistry has proven difficult to extend to primary silanes (RSiH₃), which might be expected to produce reactive

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Scheme 1. Syntheses of complexes 2a-b, 3a-c, and 4 starting from 1.

complexes of the type [$\{PhBP^{Ph}_{3}\}RuH(\eta^{3}-H_{2}Si(H)R)$]. Efforts to prepare such compounds have included the examination of reactions of arylsilanes ArSiH₃ (Ar = 2-MeOC₆H₄, Mes, Ph) with 1, which instead produced highly unusual hydridosilicate σ-complexes [{(PhBP $^{Ph}_{3}$)Ru}₂(μ-Cl){μ-η 3 ,η 3 -H₄SiAr}] (Ar = 2-MeOC₆H₄, 3a; Mes, 3b; Ph, 3c; Scheme 1), as described below. Furthermore, displacement of Ph₂SiH₂ from 2 with (m-Xyl)SiH₃ or SiH₄ results in formation of [{(PhBP^{Ph}₃)Ru}₂{μ- η^4, η^4 -H₆Si}] (4; Scheme 1), a diruthenium complex with the novel $\eta^4, \eta^4 - [H_6Si]^{2-}$ ligand.

Treatment of 1 with excess (2-MeOC₆H₄)SiH₃ (6 equiv) in C₆D₆ resulted in quantitative formation of **3a** (by ¹H and ³¹P{¹H} NMR spectroscopy) and 1 equiv of (2-MeOC₆H₄)SiH₂Cl (¹H NMR: $\delta = 5.36$ ppm, ¹ $J_{SiH} = 242$ Hz) within 30 min.[11] Compound 3a spontaneously crystallized from this solution after 24 h, and single-crystal X-ray diffraction was used to determine a dinuclear structure featuring a (2-MeOC₆H₄)Si fragment that bridges the two ruthenium centers, but the hydride ligands could not be located (Figure 1 a). Multinuclear NMR data for 3a (CD2Cl2) are consistent with a dinuclear structure that includes the [(2-MeOC₆H₄)SiH₄]⁻ anion. The 2-MeOC₆H₄ group is present in a 1:2 ratio with the [PhBPPh3] ligand, and the two {[PhBP^{Ph}₃]Ru} fragments are equivalent in the ³¹P{¹H} NMR spectrum of 3a, which displays three triplet resonances $({}^{2}J_{PP} =$

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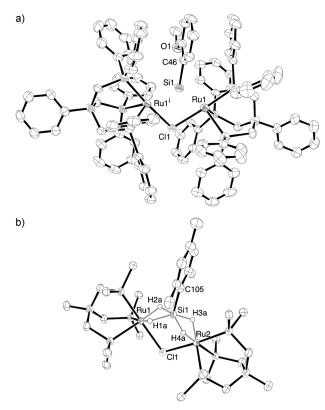


Figure 1. a) Structure of **3 a** determined by single-crystal X-ray diffraction analysis (XRD; ellipsoids set at 50% probability). [30] The OMe group is disordered equally between two positions that are related by a C_2 rotation about the Si–C46 axis. Only one orientation of the OMe group is shown, and hydrogen atoms are omitted for clarity. Si1–Ru1 2.3337(9) Å. b) Structure of **3 b** determined by single crystal XRD (ellipsoids set at 50% probability). [30] Non-hydridic hydrogen atoms and non-*ipso* phenyl carbon atoms have been omitted for clarity. Selected bond lengths [Å] and angles [°]: Si1–H1a 1.62(4), Si1–H2a 1.68(3), Si1–H3a 1.66(4), Si1–H4a 1.66(3), Si1–C105 1.871(4), Si1–Ru1 2.3659(9), Si1–Ru2 2.3599(9); H1a-Si1-H2a 84(2), H1a-Si1-H4a 87(2), H2a-Si1-H3a 86(2), H3a-Si1-H4a 88(2), C105-Si1-H1a 106(1), C105-Si1-H2a 104(1), C105-Si1-H3a 107(1), C105-Si1-H4a 104(1).

36 Hz, $\delta = 49.6$, 30.6, 30.0 ppm). Two ¹H NMR resonances, each integrating as two hydride ligands, appear near -5 ppm. The slight inequivalence of the hydride resonances is attributed to the orientation of the o-anisyl group. Hindered rotation of the Si-Ar bond in 3a may be expected based on steric interactions of the o-anisyl group with the $[PhBP^{Ph}]$ ligand that are evident in the solid-state structure. The ¹H–²⁹Si HMBC NMR spectrum has a ²⁹Si resonance at 122 ppm that exhibits similar coupling constants for the two hydride resonances (${}^{1}\text{H}$ $\delta = -4.87$, -5.11 ppm; $J_{\text{SiH}} = 84$, 77 Hz). These $J_{\rm SiH}$ values are quite large and indicate that the hydride ligands engage in non-classical Ru-H-Si interactions.[12] The Ru-H signals exhibit coalescence at -80 °C in the ¹H NMR spectrum and are separated into three broad, partially overlapping resonances at -90 °C. The new Ru-H resonances $(^{1}\text{H} \ \delta = -4.60 \ (2 \text{H}), -5.41 \ (1 \text{H}), -5.75 \ (1 \text{H}))$ feature chemical shifts that span a fairly narrow range, which suggests that all of the hydride ligands are in similar bonding environments. The FTIR spectra of 3a feature a broad absorption centered at 1720 cm⁻¹ for the solid (Nujol) or 1715 cm⁻¹ in solution (CH₂Cl₂), which further indicates the presence of Ru–H–Si bonds that have a relatively strong Si–H bonding component (see below). Notably, the 29 Si chemical shift is downfield from the range observed for η^3 -[H₂SiR₃] $^ \sigma$ -complexes (–13.8–70 ppm), $^{[4]}$ but is closer to the range observed for η^3 -H₂SiR₂ σ -complexes (141–162 ppm). $^{[10,13]}$

Treatment of 1 with an excess of MesSiH₃ (4 equiv) initially resulted in formation of a single product, which exhibited NMR data ($^{31}P\{^{1}H\}$) $\delta = 45.7$ ppm; ^{29}Si $\delta = 108$ ppm; 1 H $\delta = -6.43$ ppm, Ru–H, $J_{SiH} = 82$ Hz, 3H) comparable to that of $[{PhBP}^{Ph}_{3}]RuH(\eta^{3}-H_{2}SiRR')]$ complexes. [10,13] This complex, presumed to be [$\{PhBP^{Ph}_{3}\}RuH(\eta^{3}-H_{2}SiClMes)\}$], could not be isolated but the slow transformation of this species to 3b (50% yield), 4 (20% yield), and several minor products was evident by monitoring the reaction over one week by ¹H and ³¹P{¹H} NMR experiments. Both **3b** and **4** crystallized from the reaction solution, which prevented the isolation of **3b** in pure form. The ¹H-²⁹Si HMBC NMR spectrum (using impure 3b) revealed a ²⁹Si resonance at 116 ppm that was coupled to a hydride resonance at -4.95 ppm ($J_{SiH} = 82$ Hz). The Ru–H resonance for **3b** exhibits coalescence at -60 °C in the ¹H NMR spectum and at -90 °C is resolved into two doublets (${}^{1}H \delta = -4.73$ (2H), -5.87 ppm (2 H); ${}^{2}J_{PH} = 35.6 \text{ Hz}$). A ${}^{29}\text{Si-filtered}$ ${}^{1}\text{H-}$ $\{^{31}P\}$ NMR spectrum indicated large J_{SiH} values (>65 Hz) for each hydride resonance, but the signal-to-noise ratio was insufficient for determination of precise values. The variabletemperature NMR data for 3a,b are consistent with the solidstate structures in which 3a features C_1 symmetry (all four Ru-H resonances are inequivalent, but two overlap significantly) and 3b features C_2 symmetry (two Ru–H resonances for 4 hydride ligands). Complex 3c was similarly isolated with a small contaminant (10%) of 4 as an impurity, but it was identified by the similarity of its multinuclear NMR data to those of **3a,b** (**3c**: 29 Si $\delta = 120$ ppm, 1 H $\delta = -4.71$ ppm, Ru– $H-Si J_{SiH} = 80 Hz$).

The structure of **3b** (Figure 1b) was determined by X-ray diffraction analysis and is very similar to that of 3a, but all hydride ligand positions were located and refined for 3b. The Ru-Si distances (av. 2.3629(9) Å) are in the range typically observed for Ru-Si single bonds.[14] The silicon center features a five-coordinate, square-pyramidal geometry in which the mesityl group occupies the apical position and the hydrogen atoms occupy the basal positions. Related η^3 -[H₂SiR₃]⁻ complexes also feature a square-pyramidal geometry at silicon, [4] whereas free [RSiH₄] anions are expected to exhibit a trigonal bipyramidal geometry.^[15] Relatively short Si-H distances (<1.7 Å) indicate the presence of four coordinated Si-H bonds, which typically fall in a range from 1.50 Å (uncoordinated Si-H)^[16] to 2.00 Å (full oxidative addition). [12a,b,17] It would require inaccuracy several times greater than the estimated standard deviation for the longest measured Si-H distance in **3b** (1.68(3) Å) to have a true value beyond this 2.00 Å limit. Systematic shortening of the M-H distance is a common error in determining hydride positions by XRD, [18] and this might influence the measured Si-H distances. However, this is not apparent for the measured Ru-H distances in 3b ($d(Ru-H)_{3b}$ 1.58(4)-1.68(3) Å, av. 1.66(4) Å; $d(Ru-H)_{terminal}$ ca. 1.6 Å^[19]). The structures of **3a,b** were examined using DFT geometry optimization calculations (**3a**-DFT and **3b**-DFT), [20] which provided Si–H and Ru–H distances (dSi–H and dRu–H < 1.75 Å) that are slightly longer than those determined by XRD for **3b**, and fully consistent with coordinated Si–H bonds. Vibrational analysis of the optimized structures predicted a Ru–H stretching mode with a moderate IR intensity (1683.5 cm⁻¹ for **3a**-DFT, 1695.3 cm⁻¹ for **3b**-DFT) and weaker Ru–H absorptions at 1755.3 cm⁻¹ (**3a**-DFT) and 1757.7 cm⁻¹ (**3b**-DFT) that agree well with the broad Ru–H absorption observed at 1720 cm⁻¹ in the FTIR spectrum for **3a**.

Notably, complexes 3a-c exhibit no decomposition (determined by ¹H and ³¹P NMR) after 1 week in CD₂Cl₂ at room temperature and are thus the most stable compounds containing an [ArSiH₄]⁻ anion. The only previously isolated $[ArSiH_4]^-$ species $[Cp(iPr_2MeP)Fe(\eta^3-H_2SiPhH_2)]$ was reported to be unstable in solution, [4a] and related free $[RSiH_4]^-$ anions (R = H, alkyl, aryl) have only been studied by mass spectrometry and computational techniques.^[8,15] Free hydridosilicate anions readily transfer hydride to other species (for example ketones and CO₂) in the gas phase, [8c,d] and this is attributed to the low hydride binding energies (hydride affinity, HA) of the parent silanes (HAprimarysilane = $16-22 \text{ kcal mol}^{-1}$; [8c,d,15b] for comparison $HA_{\text{benzene}} = 21.5 \pm$ 4.2 kcal mol^{-1[21]}). The remarkable stabilization of the [ArSiH₄]⁻ anions in 3a-c was examined by NBO and NLMO calculations, [22] which indicate that all four Ru-H-Si interactions are similar in nature (see the Supporting Information). Thus, the $bis(\eta^3-H_2Si)$ coordination mode evenly removes electron density from all four electron-rich Si-H bonds such that none of the Si-H bonds are entirely broken. Note that the only previous examples of bis(η^3 -H₂Si) coordination were reported for SiH_4 complexes $[\{(R_3P)_2H_2Ru\}_2(\eta^3,\eta^3-H_4Si)]$ (R = iPr, Cy), in which substantial electron density is also withdrawn from silicon without cleavage of the Si-H bonds. [23]

The $\eta^4, \eta^4 - [H_6Si]^{2-}$ complex **4** was formed in nearly quantitative yield by reaction of m-XylSiH₃ with 2b in [D₆]benzene (by ¹H and ³¹P{¹H} NMR; Scheme 1). The mild conditions and high yield for the formation of 4 are notable because the only previous synthesis of an [SiH₆]²⁻ species involved extreme pressure and high temperature (>4 GPa, >450 °C) to convert KH, H₂, and elemental silicon into K₂SiH₆, which was detected as a minor constituent of the resulting mixture. [24] Complex 4 was isolated as a white powder in 34% yield and was characterized by NMR (CD₂Cl₂) and FTIR (Nujol, CH₂Cl₂) spectroscopy, as well as single-crystal XRD, making it the first $[SiH_6]^{2-}$ species to be isolated and characterized. All the phosphine ligands are equivalent (by ³¹P{¹H} NMR spectroscopy) and there are three hydride ligands for each {[PhBP^{Ph}₃]Ru} moiety (by ¹H NMR spectroscopy). In the ¹H{³¹P} NMR spectrum, the Ru-H resonance is a sharp singlet ($\delta = -6.41 \text{ ppm}$) that features satellites from coupling to 29 Si ($J_{SiH} = 74.5$ Hz). This data is consistent with the $\eta^4, \eta^4 - [H_6 Si]^{2-}$ structure of **4**, but could also result from a less symmetric η^3, η^3 -H₄Si structure $[\{(PhBP^{Ph}_3)RuH\}_2\{\mu-\eta^3,\eta^3-H_4Si\}]$ in which the terminal and bridging hydride positions exchange rapidly. The Ru-H resonance was broadened only slightly in the ¹H NMR spectrum collected at $-90\,^{\circ}\text{C}$, but the analogous exchange processes for 2a,b are also rapid on the NMR timescale at $-80\,^{\circ}\text{C}.^{[10]}$ The $^{1}\text{H}-^{29}\text{Si}$ HMBC NMR spectrum of 4 has a ^{29}Si resonance (162 ppm) that is considerably upfield from that of $[\{(Cy_3P)_2H_2Ru\}_2(\eta^3,\eta^3\text{-}H_4\text{Si})]$ (^{29}Si $\delta=290),^{[23]}$ arguing against an $\eta^3,\eta^3\text{-}H_4\text{Si}$ structure for 4. It is interesting that 4 features an $\eta^4,\eta^4\text{-}[H_6\text{Si}]^2$ — ligand, unlike $[\{(R_3P)_2H_2Ru\}_2(\eta^3,\eta^3\text{-}H_4\text{Si})],$ which instead exhibit a highly activated $\eta^3,\eta^3\text{-}H_4\text{Si}$ ligand and terminal Ru–H bonds. This difference suggests that fac $\eta^4,\eta^4\text{-coordination}$ is important for stabilizing $[\text{SiH}_6]^2$ — in 4, whereas the bulky trans phosphine ligands in $[\{(R_3P)_2H_2Ru\}_2(\eta^3,\eta^3\text{-}H_4\text{Si})]$ make fac coordination of $[\text{SiH}_6]^2$ — less favorable.

In the reaction of **2b** with *m*-XylSiH₃, the formation of 1 equiv Ph₂SiH₂ and 0.5 equiv of (*m*-Xyl)₂SiH₂ was detected by ¹H NMR spectroscopy, and thus the formation of **4** appears to involve redistribution of (*m*-Xyl)SiH₃ to form (m-Xyl)₂SiH₂ and SiH₄. The reaction of SiH₄ with two equivalents of [{PhBP^{Ph}₃}RuH] would provide complex **4** by coordination of each Si–H bond to a ruthenium center and transfer of the two terminal hydride ligands to the electrophilic silicon atom. ^[10] Consistent with this mechanism, the addition of excess SiH₄ to a solution of **2** in [D₆]benzene resulted in the formation of **4** and release of Ph₂SiH₂ (by ¹H NMR spectroscopy; Eq. (1)). Furthermore, the redistribution of PhMeSiH₂

to Ph_2SiH_2 , $PhMe_2SiH$, Ph_2MeSiH , Me_2SiH_2 , and $MeSiH_3$ was observed by 1H NMR spectroscopy after heating a solution of the silane and 10 mol% $\bf 2a$ in $[D_6]$ benzene to 60 °C for 20 h. Under these conditions, $\bf 2a$ was converted into $\bf 4$ in 90% yield, whereas only slight (<5%) decomposition of $\bf 2a$ to $\bf 4$ was observed in the absence of $PhMeSiH_2$. Numerous transitionmetal complexes mediate redistribution reactions of silanes, and several different mechanisms have been proposed and examined for such reactions. $[^{25}]$

The FTIR spectra of 4 show a broad absorption at 1746 cm⁻¹ (Nujol) or 1750 cm⁻¹ (CH₂Cl₂), which is consistent with the Ru-H stretching mode of an Ru-H-Si interaction.[12b] Comparison of the FTIR data for 4 with that of related {[PhBPPh3]Ru} complexes provides useful insight into the nature of the Ru-H-Si interactions. For example, the terminal Ru-H stretches for 2a,b are at 1974 cm⁻¹ (2a) and 1999 cm⁻¹ (**2b**), while the Ru-H-Si bonds provide Ru-H stretches at lower wavenumber (1666 cm⁻¹ 2a; 1643 cm⁻¹ 2b). The 4-dimethylaminopyridine adducts of **2a,b** [{PhBP^{Ph}₃}Ru- $\{(\mu-H)_3SiRR'(DMAP)\}\] (RR' = MePh 2a-DMAP; RR' = Ph_2$ **2b**-DMAP) show Ru–H stretches at 1883 cm⁻¹ (**2a**-DMAP) and 1893 cm⁻¹ (2b-DMAP). As the {[PhBP^{Ph}₃]Ru} fragment is constant amongst these species, the large differences in Ru-H stretching frequencies likely reflect the strength of the Si-H interactions. Thus, 4 appears to feature Ru-H-Si bonding in which the Si-H interactions are stronger than those in 2a,bDMAP but weaker than those of the coordinated Si–H bonds in $\bf 2a,b$. The $^2J_{\rm SiH}$ value for these compounds provides further support for this trend, with $\bf 4$ exhibiting a $J_{\rm SiH}$ value (74.5 Hz) intermediate between those for the Ru–H–Si bonds of $\bf 2a,b$ (ca. 100 Hz) and $\bf 2a,b$ -DMAP (ca. 42 Hz). [10] Complex $\bf 3a$ also features $J_{\rm SiH}$ values (77 Hz, 82 Hz) and a Ru–H stretching frequency (1720 cm⁻¹) that suggest Ru–H–Si interactions that are similar to those of $\bf 4$.

The structure of **4** was determined by XRD analysis using a crystal that was grown from a solution of **4** in toluene (**4**-tol; Figure 2a). The hydride positions revealed that **4** features an

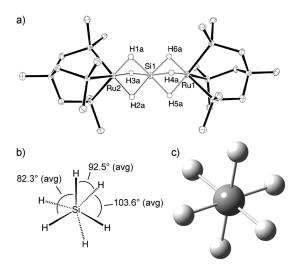


Figure 2. a) Structure of **4**-tol determined by single crystal XRD (ellipsoids set at 50% probability). ^[30] Non-hydridic hydrogen atoms, non-ipso phenyl carbon atoms, and three solvent molecules (toluene) were excluded for clarity. Selected bond lengths [Å]: Si1–H1a 1.75(3), Si1–H2a 1.77(4), Si1–H3a 1.69(4), Si1–H4a 1.69(3), Si1–H5a 1.76(4), Si1–H6a 1.79(4). b) Representation of the η^4 : η^4 -[SiH₆]²⁻ moiety from **4**-tol, viewed along the Ru-Si-Ru axis. c) Structure of the free [SiH₆]²⁻ dianion as determined by DFT methods.

[SiH₆]²⁻ anion coordinated to two {[PhBP^{Ph}₃]Ru} moieties. The six Si-H bonds are indicated by six short Si-H distances (1.69(3)–1.79(4) Å; av. 1.74(4) Å) and three Si-H bonds are coordinated to each ruthenium center (d(Ru-H) 1.62(4)-1.73(4) Å; av. 1.68(4) Å). As noted for the structure of **3b**, the Si-H distances measured for 4-tol would require inaccuracy several times greater than the estimated standard deviation to have true values beyond the range expected for Ru-H-Si bonding, while the Ru-H distances do not indicate obvious systematic errors. Additionally, the measured Si-H distances are intermediate between those determined by XRD for the Ru-H-Si interactions in **2a** $(d(Si-\mu-H)=1.61(4))$ and 1.66(4) Å) and **2b**-DMAP ($d(Si-\mu-H) = 1.82(3), 1.98(4), and$ 1.99(3) Å), which is in agreement with the trend in Si-H bond strength established by FTIR and NMR spectroscopy for this series of related complexes. Interestingly, the Ru-Si distances $(d(\text{Ru-Si}) \ 2.167(1), \ 2.168(1) \text{ Å})$ are shorter than those reported for any other ruthenium-silicon compound, a record previously held by $[\{(iPr_3P)_2H_2Ru\}_2(\eta^3,\eta^3-H_4Si)]$ $(dRu-Si = 2.1875(4) \text{ Å}).^{[23,26]}$ The two nearly identical Ru-Si distances and approximate D_3 symmetry of 4-tol suggests that all the Ru–H–Si interactions are equivalent. Each ruthenium center exhibits an octahedral geometry, and the two $\{[PhBP^{Ph}_{3}]RuH_{3}\}$ fragments are rotated by about 13° from an ideal, staggered conformation (av. P-Ru-Ru-P angle 166.48(3)°). The $\eta^4, \eta^4-[SiH_{6}]^{2-}$ anion exhibits a slight distortion from octahedral geometry, in which the two η^4 -H₃Si faces are rotated from the staggered conformation (by ca. 13°) and possess H-Si-H angles that are less than 90° (av. 82(2)°; Figure 2b). A fully staggered structure was observed with crystals of 4 grown from benzene (4-ben), but the hydride positions in this structure could not be located.

Geometry optimization calculations, [20] starting from the 4-ben structure with six Ru-H ligands added (dRu-H= 1.6 Å), produced a structure (4-DFT) that also exhibits a fully staggered conformation and features Si-H distances (1.767 Å), Ru-H distances (1.743 Å), and Ru-Si distances (2.192 Å) that are similar to those determined by XRD for 4tol. The 4-DFT structure or a slightly twisted version analogous to 4-tol were determined upon optimization of several different initial starting structures for 4, including a $[\{(PhBP^{Ph}_{3})RuH\}_{2}\{\mu-\eta^{3},\eta^{3}-H_{4}Si\}]$ structure in which the {[PhBP^{Ph}3]Ru} fragments were in a significantly different initial orientation than those of 4-DFT. Vibrational analysis of 4-DFT determined strongly IR active Ru-H stretching modes with frequencies of $1722.23~\text{cm}^{-1}$ and $1731.91~\text{cm}^{-1}$ that are in good agreement with the FTIR data for 4 (1750 cm⁻¹). This confirms that the calculations are accurate with respect to the nature of the Ru-H-Si interactions, which is expected based on the typical accuracy of DFT calculations with regard to transition-metal hydride complexes.^[19b,27]

Several resonance structures may be considered for **4**, which depict different levels of Si–H bond cleavage and corresponding levels of Ru \rightarrow Si back-donation (**A**–**C**; Figure 3). Related [L₃MH₃SiR₃] species that feature short Si–H contacts (d(Si–H) 1.86(2)–2.06(4) Å) have been described as M^{IV} silyl complexes with additional M–H···Si interactions (related to structure **B**). The M–H···Si interactions were described in terms of the hydride ligands donating into the Si–R and M–Si σ^* -orbitals. If the latter interaction were strong, it would represent a reductive

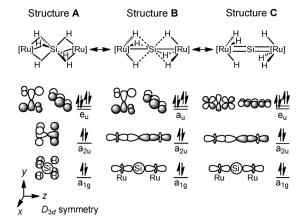


Figure 3. Resonance structures depicting increasing levels of Si-H bond activation in 4, and the bonding orbitals around silicon corresponding to each resonance structure.

elemination of the three Si-H bonds to give MII structures of the type $[L_3M\{\eta^4-H_3SiR_3\}]$ (related to structure **A**), but examples of this have never conclusively been shown. [5,6] The resonance structures in Figure 3 feature a similar distinction between a bis-Ru^{II} hexahydridosilicate structure (A) and a bis-Ru^{IV} structure featuring two Ru-Si σ-bonds and weaker Ru–H···Si interactions (B). Bonding motifs analogous to structure B have been reported for structurally related $[\{(R_3P)_3Fe\}_2(\mu-H)_6B]^+$ complexes^[28] and an additional bonding description for 4 features a Ru=Si=Ru core and no Si-H bonding (structure C). The short Si-H distances in 4 are consistent with structures A or B and the short Ru-Si distances and downfield ²⁹Si NMR resonance could indicate Ru=Si character (structure C). [26] However, as already noted, the Ru–H stretching frequency and large $J_{\rm SiH}$ values for 4 are characteristic of coordinated Si-H bonds and, thus, strongly support the greater importance of resonance structure A. For comparison to 4, the structure of the hypothetical free [SiH₆]²⁻ anion was determined using DFT methods $([SiH_6]^{2-}\text{-}DFT;\ Figure\,2\,c)^{[20]}$ and displays an octahedral geometry (H-Si-H = 90°) with Si-H distances (1.66 Å) that are somewhat longer than those of silane Si-H bonds (ca. 1.5 Å). The Si–H bonds in 4 are only ca. 0.1 Å longer than those in $[SiH_6]^{2-}$ -DFT, which supports structure ${\bf A}$ as the best bonding description for 4, as each Si-H bond is weakly activated in the η^4, η^4 -[SiH₆]²⁻ ligand.

Further support for the importance of structure A was found by examining the molecular orbitals for 4-DFT (Figure 4). The most significant Ru–Si σ-bonding interaction was found in the HOMO-46 orbital, which includes a significant contribution from two ruthenium 4d_{z²} orbitals (9% each) with a smaller contribution from the silicon 3p, orbital (3%). This represents a dative Ru→Si interaction that is consistent with weak back-donation into one of the SiH₆ σ* orbitals, whereas oxidative addition to give structures **B** or **C** should result in two full Ru-Si σ-bonds, formed by interaction of the a_{1g} and a_{2u} linear combinations of ruthenium $4d_{z^2}$ orbitals with the silicon 3s (a_{1g}) and $3p_z$ (a_{2u}) orbitals (Figure 3). The HOMO-179 and HOMO-154 molecular orbitals depict Ru-H-Si bonding interactions that correspond to the a_{1g} and a_{2u} orbitals of structure **A** interacting with a_{1g} and a_{2u} combinations of the ruthenium 5s orbitals. The nearly degenerate HOMO-127 and HOMO-128 also include substantial Ru-H-Si bonding character, which corresponds to the e_n Si-H bonding orbitals in structure **A** interacting with 4d orbitals on ruthenium. These two orbitals resemble the π bonding orbitals for structure C and this may contribute to the relatively downfield ²⁹Si chemical shift for **4**. Further similarity to structure C is found in the LUMO and LUMO+1 orbitals of 4-DFT, which include substantial silicon 3p character and resemble the degenerate π^* -LUMOs expected for a Ru=Si=Ru bonding motif. A similar analogy has been noted between the LUMOs of $M(\eta^3-H_2SiR_2)$, $M(\mu-H)SiR_2$, and M(H)₂=SiR₂ complexes and is due to the inability of the hydrogen 1s orbital to contribute to the out of phase combination of the ruthenium 4d orbital with the silicon 3p orbital. [10,29] This also applies to 4, despite hypercoordination at silicon, and is possible because all six Si-H bonds engage in Ru-H-Si interactions.

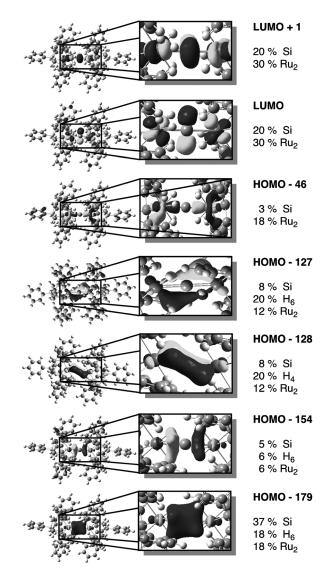


Figure 4. Selected molecular orbitals of 4-DFT and percent contribution from silicon, the two ruthenium atoms, and six hydride ligands.

The bonding in **4** was also examined using NBO calculations on a slightly modified version of **4**-DFT. The NBO analysis provided a relatively poor bonding description for **4**, which is expected for a highly delocalized structure. However, the NPA and NBO outputs both indicate that each ruthenium has three fairly high occupancy 4d orbitals, consistent with a bis-Ru^{II} description. An NLMO analysis provided a better description of the bonding in **4**, including six nearly identical NLMOs that consist almost entirely of atomic functions on hydrogen (51%), silicon (25%), ruthenium (13%), and phosphorus (8.5%). The only indication of Ru–Si σ -bonding was found in two NLMOs almost entirely composed of ruthenium 4d character (94.5%), with a slight contribution from silicon (3%).

In summary, reactions of primary aryl silanes with 1 or 2 resulted in the formation of novel diruthenium hydridosilicate σ -complexes 3a–c or 4, respectively. Complexes 3a–c feature unique examples of bridging η^3,η^3 -[H₄SiAr]⁻ ligands and are more stable than the only previously isolated [ArSiH₄]⁻

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species, which featured an η^3 -[H₂SiH₂Ph]⁻ ligand in a mononuclear Fe^{II} complex. Complex **4** is the first isolated compound to include an [SiH₆]²⁻ dianion, which in this case is bound as a bridging η^4, η^4 -[H₆Si]²⁻ ligand. This is particularly notable because hydridosilicate dianion σ -complexes had not been conclusively demonstrated, but have been the subject of ongoing discussion. The stability of the hydridosilicate anions in **3a-c** and **4** is attributed to the unique ability of the two ruthenium centers in these complexes to uniformly remove electron density from the Si–H bonds.

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